

L Number	Hits	Search Text	DB	Time stamp
1	33	((quartz or SiO.sub.2) same ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/08 17:09
8	9	((quartz or SiO.sub.2) and ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition") not (((quartz or SiO.sub.2) same ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/08 15:13
15	395	((quartz or SiO.sub.2) and ("silicon nitride" or Si.sub.3 N.sub.4)) and protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition") not (((quartz or SiO.sub.2) same ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")) or (((quartz or SiO.sub.2) and ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition") not (((quartz or SiO.sub.2) same ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition"))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/08 17:09
22	358	((quartz or SiO.sub.2) and ("silicon nitride" or Si.sub.3 N.sub.4)) and protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition") not (((quartz or SiO.sub.2) same ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")) or (((quartz or SiO.sub.2) and ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition") not (((quartz or SiO.sub.2) same ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")))) and (chamber or reactor or vessel or tank)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/08 15:19
29	1	(US-20020192370-\$.did.	US-PGPUB	2003/01/08 15:20
30	1	(US-20020011211-\$.did.	US-PGPUB	2003/01/08 15:23
31	27	((("6198074") or ("6133550") or ("6046439") or ("6002109") or ("5958510") or ("5958140") or ("5772770") or ("5695564") or ("5680502") or ("5651827") or ("5536918") or ("5520742") or ("5462603") or ("5387557") or ("5252807") or ("5207573") or ("5119761") or ("5011794") or ("5001327") or ("4914276") or ("4857689") or ("4794217") or ("4770630") or ("4672915") or ("4641603") or ("4496609") or ("4481406")).PN.	USPAT	2003/01/08 17:04
32	4	((("6198074") or ("6133550") or ("6046439") or ("6002109") or ("5958510") or ("5958140") or ("5772770") or ("5695564") or ("5680502") or ("5651827") or ("5536918") or ("5520742") or ("5462603") or ("5387557") or ("5252807") or ("5207573") or ("5119761") or ("5011794") or ("5001327") or ("4914276") or ("4857689") or ("4794217") or ("4770630") or ("4672915") or ("4641603") or ("4496609") or ("4481406")).PN.) and (quartz or SiO.sub.2) and ("silicon nitride" or Si.sub.3 N.sub.4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/08 17:05
46	11983	(quartz or SiO.sub.2) and ("silicon nitride" or Si.sub.3 N.sub.4) and prevent\$3 and (CVD or \$5CVD or "vapor deposition") not (((quartz or SiO.sub.2) same ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")) or (((quartz or SiO.sub.2) and ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition") not (((quartz or SiO.sub.2) same ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")))) or (((quartz or SiO.sub.2) and ("silicon nitride" or Si.sub.3 N.sub.4)) and protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition") not (((quartz or SiO.sub.2) same ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")) or (((quartz or SiO.sub.2) and ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition") not (((quartz or SiO.sub.2) same ("silicon nitride" or Si.sub.3 N.sub.4)) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")))) and (chamber or reactor or vessel or tank))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/08 17:13

74	97	<p>(((quartz or SiO.sub.2') and ("silicon nitride" or Si.sub.3 N.sub.4') and (CVD or \$5CVD or "vapor deposition") not (((quartz or SiO.sub.2') same ("silicon nitride" or Si.sub.3 N.sub.4')) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")) or (((quartz or SiO.sub.2') and ("silicon nitride" or Si.sub.3 N.sub.4')) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition") not (((quartz or SiO.sub.2') same ("silicon nitride" or Si.sub.3 N.sub.4')) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")))) or (((quartz or SiO.sub.2') and ("silicon nitride" or Si.sub.3 N.sub.4')) and protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition") not (((quartz or SiO.sub.2') same ("silicon nitride" or Si.sub.3 N.sub.4')) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")) or (((quartz or SiO.sub.2') and ("silicon nitride" or Si.sub.3 N.sub.4')) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")))) and (chamber or reactor or vessel or tank)))) and corrosiv\$3 not (((quartz or SiO.sub.2') and ("silicon nitride" or Si.sub.3 N.sub.4') and (CVD or \$5CVD or "vapor deposition") not (((quartz or SiO.sub.2') same ("silicon nitride" or Si.sub.3 N.sub.4')) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")) or (((quartz or SiO.sub.2') and ("silicon nitride" or Si.sub.3 N.sub.4')) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")) not (((quartz or SiO.sub.2') same ("silicon nitride" or Si.sub.3 N.sub.4')) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")))) or (((quartz or SiO.sub.2') and ("silicon nitride" or Si.sub.3 N.sub.4')) and protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition") not (((quartz or SiO.sub.2') same ("silicon nitride" or Si.sub.3 N.sub.4')) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")) or (((quartz or SiO.sub.2') and ("silicon nitride" or Si.sub.3 N.sub.4')) same protect\$3) and thermocouple and (CVD or \$5CVD or "vapor deposition")))) and (chamber or reactor or vessel or tank)))) and corrosivi\$3)) and lifetime</p>	<p>USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB</p>	2003/01/08 17:24
----	----	---	--	------------------